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On determination of $Cd_{1-x}Zn_xTe$ composition from an analysis of the 4.2, 77 and 295 K edge photoluminescence spectra

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> Abstract. The known and obtained in this work dependences of the 4.2, 77 and 295 K peak positions hv_m of the Cd_{1-x}Zn_xTe edge emission bands induced by: (a) annihilation of free X and bound on shallow neutral acceptors A^0 or shallow neutral donors D^0 excitons A^0X and D^0X and (b) recombination of free and shallow donor bound electrons with free holes on $Cd_{1-x}Zn_xTe$ composition x (x ≤ 0.28) are analyzed in detail. It is shown that the 4.2 K peak position of the A^0X induced emission band used for the exact x determination could be related with some problems arising from variety of the 4.2 K $hv_m(A^0X)$ vs. x dependences. As a result of the pointed problem, analysis of the 4.2 K $hv_m(A^0X)$ vs. x dependences permits to find the x value with some inaccuracy (some unknown factors shift the energy position of the A^0X bound exciton are responsible for this fact). The noticeable (differing from the expected theoretical ones) differences of the peak positions of emission bands hv_m induced by radiative annihilation of D^0X bound excitons at 295 K, radiative recombination of donor bound electrons D^0 with free holes h at 300 K and radiative annihilation of free electrons e and holes at 300 K, *i.e.* of 295 K $hv_m(D^0X)$, 300 K $hv_m(D^0h)$ and 300 K $hv_m(eh)$ values, accordingly, vs. x dependences are observed and briefly analyzed.

> **Keywords:** $Cd_{1-x}Zn_xTe$ composition, photoluminescence, free and bound excitons, accuracy of composition determination.

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1. Introduction

Peak positions hv_m of the edge emission bands induced by: (a) radiative annihilation of bound (by shallow neutral acceptors A^0 or shallow neutral donors D^0) A^0X or D^0X excitons (the dissociation paths are $A^0X \rightarrow$ $A^0 + hv$ and $D^0X \rightarrow D^0 + hv$), (b) radiative transitions of electrons bound neutral shallow donors D^0 with the holes h (the dissociation path is $D^0 + h \rightarrow D^+ + hv$), c) radiative annihilation of free exciton X, d) radiative recombinations of free electrons e and holes h in mixed $Cd_{1-x}Zn_xTe$ compounds depend strongly on their chemical composition x, *i.e.* on the zinc content x (the hv_m values shift to higher energies as x is increased) [116]¹. So, the luminescent method – measurements of the 1.6 [8], 2 [4], 4.2 [1, 5, 9, 10, 13], 12 [2], 77 [6], 80 K [3] and room temperature T = 295...300 K [2, 7, 11] peak positions of the edge emission bands in principle could be used for finding composition of

¹ In many of the cited works the band gap energy E_g vs. x dependences are given. They were found from the obtained in the experiment peak positions of the exciton (carrier) induced emission hv_m vs. x dependences by taking into account exciton (carrier) binding energies. So, in the pointed cases the given below hv_m vs. x dependences were plotted from the known E_g vs. x dependences by taking into account the corresponding exciton (carrier) binding energies (see below).

 $Cd_{1-x}Zn_xTe$ crystals and films. Obviously, the most convenient for this purpose are measurements of the hv_m values at temperatures T = 4.2, 77 and 295...300 K. Below we will analyze the known and obtained in this work (found by an analysis of the A^0X , D^0X , D^0h , X and e-h induced emission band) the 4.2, 77 and 295...300 K hv_m vs. x dependences for x determination in Cd_{1-x}Zn_xTe. In particular the strict analysis of the 4.2, 77 and 300 K bound exciton induced emission bands A^0X and D^0X in $Cd_{1-x}Zn_xTe$ crystals with the different Zn content and various temperatures was a basis for obtaining presented by us the 4.2, 77 and 295 K $hv_m(A^0X, D^0X)$ vs. x dependences. We will find the accuracy of the xdetermination by measuring the 4.2 K A^0X induced luminescence bands and show that the same problems arise, when we use the 4.2 K $hv_m(A^0X)$ vs. x dependences for x determination. They results from unexpected variety of the observed 4.2 K $hv_m(A^0X)$ vs. x dependences for Cd_{1-x}Zn_xTe crystals. The reasons leading to variety of the 4.2 K $hv_m(A^0X)$ vs. x dependences are discussed. We also discuss the notable unexpected difference of the 295 K $hv_m(D^0X)$, 300 K $hv_m(D^0h)$ and 300 K $hv_m(eh) = \varphi(x)$ calibration curves. Finally, in the Appendix obtained by us photoluminescence characteristics of A^0X and D^0X induced emission bands in $Cd_{1-x}Zn_xTe$ crystals ($x \le 0.28$ and T = 4.2 - 295 K) will be presented (peak emission intensities, emission peak positions and half-widths of A^0X and D^0X induced emission bands will be given). These data will be helpful for identification of the A^0X and D^0X induced emission bands in the $Cd_{1-x}Zn_xTe$ crystals with moderate x (≤0.28) and *T* (4.2–295 K) value.

2. Experimental

Semi-insulating, *i.e.* the specific resistivity $\rho \ge$ 10⁵ Ohm·cm at $T \le 295$ K ($\rho \approx 3.10^9$ Ohm·cm) at room temperature and $\rho \rightarrow \infty$ at $T \leq 77$ K for crystals with x = 0.1, Cd_{1-x}Zn_xTe crystals with the known x values 0, 0.04, 0.1, 0.2 and 0.28 (x = 0.04 and 0.1 were found by the X-ray diffraction measurements and x = 0.2 and 0.28 - by the X-ray spectral microanalysis) were used to find the given below 4.2, 77 and 295 K $hv_m(A^0X, D^0X)$ vs. x, 1/T dependences from the analysis of corresponding edge emission spectra. Luminescence was excited using the He-Ne laser (energy hv = 1.96 eV, the excitation intensity $L = 10^{18} \text{ guanta/cm}^2 \cdot \text{s}$). The MDR-23 spectrometer was used to analyze (with inaccuracy $\pm 0.2 \text{ meV}$ at 4.2 K and $\pm 1 \text{ meV}$ at 295 K) the photoluminescence spectra (the line-shapes of the A^0X and D^0X emission bands (their peak positions hv_m and half-widths w) were found). The hv_m values for the examined emission bands did not depend on the intensity of photoluminescence excitation. Before photoluminescence measurements, the $Cd_{1-x}Zn_xTe$ crystals were polished in a bromide-methanol etchant.

3. Results and discussion

3.1. The 4.2 K hv_m vs. x dependences

Fig. 1 illustrates the known (see [1, 5, 9, 10, 13]) and obtained in this work the 4.2 K $h\nu_m(A^0X)$, $h\nu_m(D^0X)$ and $h\nu_m(X)$ vs. *x* dependences for determination of $Cd_{1-x}Zn_xTe$ composition. Below, we shall discuss in detail the origin (identification) of radiative transitions responsible for above pointed 4.2 K $h\nu_m$ vs. *x* calibration dependences.

(a) The 4.2 K peak position of the A^0X induced emission $hv_m(A^0X)$ vs. x calibration dependences. 1) The 4.2 K E_g vs. x dependences (x ≤ 0.065) are given in [5, 10]. They were found by adding the A^0X exciton binding energy $\varepsilon_{bA} = 16 \text{ meV}$ to the measured $hv_m(A^0X)$ vs. x dependences (it is assumed that $\varepsilon_{bA} \neq \varphi(x)$). So, the given in [5, 10] band gap E_g vs. x dependences were replotted by us into primary dependences hv_m $(A^0X) = E_g - \varepsilon_{bA}$ vs. $x \ (x \le 0.065 - 0.07)$ by taking into account the ε_{bA} value. They are shown in Fig. 1, curves 1, 2 and 2'. 2) The 4.2 K $hv_m(A^0X)$ vs. x calibration dependences are also given in [1,9] and presented in Fig. 1 (curves 3 and 4). Obtained by us 4.2 K $hv_m(A^0X)$ vs. x dependence is given in Fig. 1 (see the curves 5), too. This dependence is really the 4.2 K $hv_m(A^0X)$ vs. x dependence as follows, on the one hand, from the coincidence for crystal with x = 0 of the observed 4.2 K hv_m value 1.590 eV with the 4.2 K $hv_m(A^0X)$ value, and, on the other hand, with the observed rather high halfwidth of emission band analyzed². In the inset of Fig. 1, the 4.2 K line shapes of the A^0X induced emission bands in $Cd_{1-x}Zn_xTe$ crystals are shown ($hv_m = 1.613 \text{ eV}$ and w = 3.6 meV for a crystal with x = 0.04 and $hv_m =$ 1.654 eV and w = 11.6 meV for a crystal with x = 0.2). Note that given here and in the Appendix 4.2 K hv_m $(A^{0}X)$ vs. x dependences could be used to identify the 4.2 $A^{0}X$ induced emission band in $Cd_{1-x}Zn_{x}Te$ crystals with moderate x values. The 4.2 K line shapes of the A^0X induced emission band in Cd1-xZnxTe crystals with different x values are also given in the Appendix.

(b) The 4.2 K peak position of the D^0X induced emission band hv_m (D^0X) vs. x calibration curve. The obtained by us 4.2 K $hv_m(D^0X)$ vs. x calibration curve is given in Fig. 1 (curve 6). The D^0X identification of the pointed emission was made on the basis of its 4.2 K peak position for this band at x = 0 (1.594 eV, it coincides with the known 4.2 K $hv_m(D^0X)$ value at x = 0) and its

² The A^0X induced emission band in 4.2 K Cd_{1-x}Zn_xTe edge luminescence spectrum could be identified due to its comparatively high half-width as compared with the corresponding for the D^0X induced emission band (see, for example, [1, 11, 14, 17] and below). In addition to the stated, some other arguments how to identify the A^0X induced emission band in the 4.2 K Cd_{1-x}Zn_xTe edge luminescence spectrum, when in it only one of two excitonic emission bands are observed are given in [15, 16].

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rather small at low x 4.2 K half-width w = 0.3 meV [15, 16]. The 4.2 K line shapes of the D^0X induced emission bands in Cd_{1-x}Zn_xTe crystals are given in the inset of Fig. 1: $hv_m = 1.617 \text{ eV}$ and w = 1.5 meV for a crystal with x = 0.04 and $hv_m = 1.667 \text{ eV}$ and w = 4.7 meV for a crystal with x = 0.2. The 4.2 K line shapes of the D^0X induced emission bands for crystals with different x values are also given in Appendix. Given here and in the Appendix 4.2 K $hv_m(D^0X)$ vs. x dependences could be used to identify the 4.2 K induced emission band in Cd_{1-x}Zn_xTe crystals with moderate x values.

(c) The 4.2 K peak position of the free exciton induced emission $hv_m(X)$ vs. x calibration dependence. In [13] E_g vs. x calibration dependence ($x \le 0.055$) is given. It was obtained by adding to the found 4.2 K $hv_m(X)$ vs. x dependence the free exciton binding energy $\varepsilon_X = 10$ meV. So, the given in [13] E_g vs. x dependence was replotted by us into $hv_m(X) = \varphi(x)$ primary dependence $hv_m(X) = E_g(x) - \varepsilon_X$ vs. x ($x \le 0.05$) by taking into account the ε_X value. Then, thus obtained the 4.2 K peak position of the free exciton induced emission band $hv_m(X)$ vs. x calibration dependence is given in Fig. 1, curve 4 (no convenient form of the 4.2 K free exciton induced emission band is given it [13]).

Naturally, in principal all the shown in Fig. 1 4.2 K dependences $hv_m(X)$, $hv_m(A^0X)$ and $hv_m(D^0X)$ on x could be used to find the x value, if the A^0X , D^0X and X induced emission bands are reliably identified in the excitonic luminescence spectra. But some difficulties arise, when one tries to use for x determination the 4.2 K peak position of the A^0X induced emission band vs. x dependences. Really, the shown in Fig. 1 4.2 K $hv_m(A^0X)$ vs. x dependences obtained by different authors somewhat strongly differ, *i.e.* a number of 4.2 K $hv_m(A^0X)$ vs. x dependences are observed. Naturally, the stated above will result in variety of x values for the fixed 4.2 K $hv_m(A^0X)$ value. It mainly refers to the $Cd_{1-x}Zn_xTe$ crystals with the low Zn content ($x \le 0.065$). Really, for example, if the measured 4.2 K hv_m value is 1.62 eV, then x = 0.056 as it follows from the 4.2 K $hv_m(A^0X)$ vs. x dependences given by the curves 1, 2, 2' of Fig. 1, and $x = 0.09 \pm 0.01$, if the 4.2 K $hv_m(A^0X)$ vs. x dependences given by the curves 3 to 5 in Fig. 1 are used for x determination. So, if one uses for x determination the 4.2 K $hv_m(A^0X)$ vs. x dependences given in [1, 5, 9, 10], the obtained x value is $x = x_0 + \Delta x =$ 0.073 ± 0.012 (x₀ is the average x value and Δx is deviation of the x value from the average one), *i.e.* is found with a rather low accuracy (the relative inaccuracy of x determination $\Delta x/x_0 \approx \pm 23\%$ is rather large). So, only rough estimates of the low (≤ 0.06) x values could be made by using the given in [1, 5, 9, 10] (see the curves 1 to 4) 4.2 K $hv_m(A^0X)$ vs. x dependences. On the contrary, for crystals with a moderate Zn content (x = 0.065...0.28) the relative inaccuracy of x determination is rather small $(\pm 5\%)$ due to a small difference at the pointed x values of the 4.2 K $hv_m(A^0X)$ vs. x dependences found in [1, 9] (see curves 3 and 4) and in this work (see curve 5). For example, if the measured 4.2 K hv_m vs. x value is 1.65 eV, then the obtained x values are 0.18 and 0.20, *i.e.* $x = 0.19 \pm 0.01$, and a relative inaccuracy $\Delta x/x_0$ is $\pm 5\%$, as it follows from the 4.2 K hv_m vs. x dependences given by the curves 3 to 5 in Fig. 1.



Fig. 1. The 4.2 K peak positions of emission bands hv_m in $Cd_{1-x}Zn_xTe$ induced by annihilation of: (a) bound excitons A^0X (*I* to 5), where *I* – data of [5]; 2, 2' – data of [10]; 3 – data of [9]; 4 – data of [1]; 5 – data obtained in the present work; (b) D^0X bound excitons (6 – data obtained in the present work); (c) free excitons X (7 – data of [13]) vs. $Cd_{1-x}Zn_xTe$ composition *x* are given. In the inset, the 4.2 K line shapes of emission bands induced in the studied $Cd_{1-x}Zn_xTe$ crystals by annihilation of A^0X and D^0X bound excitons are given (the corresponding hv_m and *w* values are given in the text).

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Now, we will discuss the possible reasons leading to a difference in the observed 4.2 K $hv_m(A^0X)$ vs. x dependences, *i.e.* to different energy positions of the A^0X bound exciton at a given x. We do not think the main reason leading to a discussed differences of the 4.2 K $hv_m(A^0X)$ vs. x dependences is a different origin of the A^0 constituents in the A^0X bound exciton, *i.e.* the stated above could be hardly related with the different origin of shallow acceptors A^0 that are constituents of the A^0X complexes. Really, the observed difference in the discussed 4.2 K $hv_m(A^0X)$ vs. x dependences is usually greater than the expected one, if one analyze the possible shift of the A^0X bound exciton energy position due to different A^0 constituents [15, 18-20]. The effect of different A^0 constituents of the A^0X complexes on the 4.2 K $hv_m(A^0X)$ value in CdTe and ZnTe compounds are given in [15, 18-20]; as one can see, usually the different A^0 constituents of A^0X complexes could only relatively weakly influence the 4.2 K peak position of the A^0X induced emission band in CdTe and ZnTe and most probably in $Cd_{1-x}Zn_xTe$, too.

We think that a row of not exactly known factors mainly influence the 4.2 K peak position of the A^0X induced emission band in Cd_{1-x}Zn_xTe. Apparently, these factors are related with the crystal perfection and structural defects [14, 21], compositional disorder [22], crystalline quality [23] and other [12]³. These factors could differ in various crystals. As a result, a number of 4.2 K hv_m values at fixed x values for the emission band induced by annihilation of A^0X complexes appear. So, variety of the 4.2 K hv_m vs. x dependences are observed as a result of some feebly controlled factors influencing the peak position of the A^0X induced emission band. A further work is needed to elucidate reasons leading to different A^0X induced 4.2 K hv_m values at a given x.

3.2. The 77 K $hv_m(D^0X)$ vs. x calibration curve

Fig. 2 shows the found in this work dependence of the 77 K peak position of emission induced by annihilation of D^0X bound exciton vs. the zinc content x in Cd_{1-x}Zn_xTe crystals. The D^0X emission band dominates in the 77 K Cd_{1-x}Zn_xTe emission spectra (see also the Appendix). In the experiment, 77 K $hv_m(D^0X) = 1.5839$ eV at x = 0. The 77 K line shapes of the D^0X induced emission bands are shown in the inset of Fig. 2: $hv_m(D^0X) = 1.6372$ eV and $w(D^0X) = 1.6543$ eV and $w(D^0X) = 1.6543$ eV and $w(D^0X) = 15.8$ meV for a crystal with x = 0.1 and $hv_m(D^0X) = 1.6543$ eV and $w(D^0X) = 15.8$ meV for a crystal with x = 0.2. Thereof, the pointed 77 K line-shapes could be used to identify



Fig. 2. The 77 K peak positions of the D^0X induced emission bands vs. *x* dependence in $Cd_{1-x}Zn_xTe$ crystals. In the inset, the 77 K line shapes of the D^0X induced emission band in $Cd_{1-x}Zn_xTe$ crystals is shown (the corresponding hv_m and *w* values are given in the text).

the 77 K D^0X induced emission band in Cd_{1-x}Zn_xTe crystals with moderate x values⁴.

3.3. 295–300 K hv_m vs. x calibration curves

The known and found by us the 293...300 K hv_m vs. x calibration curves are as follows in their origin (see Fig. 3) [2, 7, 11].

(a) The 295 K $hv_m(D^0X)$ vs x calibration dependence. The 295 K peak positions of the D^0X induced emission band $hv_m(D^0X)$ vs x calibration curve found in this work is given in Fig. 3 (curve 1). In the experiment, 295 K $hv_m(D^0X) = 1.5025$ eV at x = 0. The 295 K line-shape of the D^0X induced emission band at different x are given in Fig. 3, inset and in the Appendix: $hv_m = 1.537$ eV and w = 41.3 meV for x = 0.1, and $hv_m = 1.567$ eV and w = 41 meV for x = 0.2. The given line shapes at 295 K for the induced emission band in Cd_{1-x}Zn_xTe crystals with moderate x value could be used to identify the pointed edge emission band in Cd_{1-x}Zn_xTe crystals widely used for detector fabrication [12]⁵.

³ Naturally, the pointed factors depend substantially on the $Cd_{1-x}Zn_xTe$ growth technology (or its details, if growth technology is near by the same) that could differ significantly in various laboratories, *i.e.* they are technology dependent.

⁴ In [6], the data about 77 K PBE (principal bound exciton) induced emission in $Cd_{1-x}Zn_xTe$ crystals with different zinc content were given. In principle the 77 K $hv_m(PBE)$ vs. *x* dependence could be found from the pointed data. But the use of the given in [6] data about PBE induced exciton bands in crystals with different *x* could be hardly used for *x* determination as no exact identification of the origin of the PBE induced emission was given in [6]. So, no 77 K $hv_m(PBE)$ vs. *x* dependence is given by us.

⁵ Note that the 300 K line-shapes of the edge emission induced by radiative transitions are given in [24].



Fig. 3. The peak positions of the emission bands hv_m induced by: (a) annihilation of bound exciton D^0X at 295 K (1) (the data obtained in these work); (b) $D^0 \rightarrow h$ transitions at T = 300 K (2); (c) $e \rightarrow h$ recombination at 300 K (3) vs. x dependences in Cd_{1-x}Zn_xTe crystals. In the inset: (a) the 295 K line shapes of the D^0X emission band; (b) the 300 K line shapes of the $e \rightarrow h$ induced emission band in Cd_{1-x}Zn_xTe crystals with different x are given (the corresponding hv_m and w values are shown in the text).

(b) The 293–300 K $hv_m(D^0 \rightarrow h)$ vs x calibration dependence. The 300 K band gap E_g vs x dependence is really given in [7]. It was obtained the ε_d value by adding to the really measured 300 K peak positions of emission induced by radiative annihilation of shallow donor bound electrons (the donor ionization energy $\varepsilon_d =$ 0.013 eV) with free holes h (by $D^0 \rightarrow h$ radiative transitions). So, the given in Fig. 3 (curve 2) 300 K peak position of emission induced by $D^0 \rightarrow h$ transitions $hv_m(D^0 \rightarrow h)$ was obtained by subtracting the ε_d value from the given in [7] E_g vs x dependence. No convenient 300 K line shapes of D^0h induced emission band was given in [7].

(c) The 300 K $hv_m(e \rightarrow h)$ vs x calibration dependence. The 300 K peak positions of the emission induced by recombination of free electrons and holes $(e \rightarrow h \text{ transitions}) hv_m(e \rightarrow h)$ vs. x calibration dependence is really given in [2] and is replotted in Fig. 3. The 300 K line shape of the *eh* induced emission band shown in the inset *b* of Fig. 3. As can be shown, the main contribution to the 300 K peak intensity of the *e*-*h* induced emission band is given by the free charge carriers located inside the conduction and valence bands (at the energy $\varepsilon^* = kT/2$ from the edges of conduction (valence) bands). The free charge carriers concentrations are at maximum inside (the pointed bands).

As a result, the relation 300 K $hv_m(eh) > 300$ K E_g holds, theoretically 300 K $hv_m(eh) = 300$ K $E_g + kT/2$) [15].

Naturally, the pointed in (a), (b) and (c) 293–300 K hv_m vs. x calibration curves could be used to find the x value, if the emission bands are reliably identified⁶.

(d) Comparison of the 295 K $hv_m(D^0X) = \varphi(x)$, 300 $K h v_m(D^0 h) = \varphi(x)$ and 300 K $h v_m(eh) = \varphi(x)$ calibration dependences in $Cd_{1-x}Zn_xTe$ crystals. The shapes of the 295 K $hv_m(D^0X)$, 300 K $hv_m(D^0h)$ and 300 K $hv_m(eh)$ vs. x calibration dependences in $Cd_{1-x}Zn_xTe$ crystals notably differ, *i.e.* the 295 K $hv_m(D^0X)$, 300 K $hv_m(D^0h)$ and 300 K $hv_m(eh)$ values depend differently on x (see Fig. 3, curves 1 to 3). This fact is unexpected. Really, the mentioned 295 K $hv_m(D^0X)$, 300 K $hv_m(D^0h)$ and 300 K $hv_m(eh)$ vs. x variations are mainly determined by the corresponding bandgap E_g vs. x variations. Evidently, at any x and T values $hv_m(D^0X) = \varphi(E_g, T, \varepsilon_{bD}),$ $hv_m(D^0h) = \varphi(E_g, T, \varepsilon_d)$ and $hv_m(eh) = \varphi(E_g, T)$, where the donor ionization energy ε_d and the binding energy of the D^0X exciton ε_{bD} most probably depend weakly on x $(\varepsilon_{bD} \approx 14 \text{ meV } [14]; \text{ undoubtedly, } E_g \text{ vs. } x \text{ variations are}$ close to each other at T = 295 and 300 K).

One expects to observe similar (identically dependent on *x*) the 295 K $hv_m(D^0X)$, 300 K $hv_m(D^0h)$ and 300 K $hv_m(eh)$ vs. *x* calibration dependences. Therefore, a new more precise strict analysis of reason leading to the discussed difference of experimental and theoretical shapes of 295 K $hv_m(D^0X)$, 300 K $hv_m(D^0h)$ and 300 K $hv_m(eh)$ vs. *x* calibration dependences in needed. May be, this new analysis will explain the observed difference of shapes of 295 K $hv_m(D^0X)$, 300 K $hv_m(D^0h)$ and 300 K $hv_m(eh)$ vs. *x* calibration dependences⁷.

⁶ The 300 K hv_m vs. x dependence (hv_m values characterize the edge emission) is given in [11]. But exact identification of the pointed emission (*i.e.* transitions leading to its appearance) was not made. So, this dependence is not given here.

⁷ It is not excluded that some weakly controlled factors influence the 295 K $hv_m(D^0X)$, 300 K $hv_m(D^0h)$ and 300 K $hv_m(eh)$ values, thus leading to some deflection between experimental and theoretical hv_m values (see above).

(e) Comparison of the $hv_m(D^0X, A^0X)$ vs. x calibration dependences at T = 4.2, 77 and 295 K in $Cd_{1-x}Zn_xTe$ crystals. Fig. 4 shows the obtained by us (see above) $hv_m(D^0X)$ and $hv_m(A^0X)$ vs. x calibration dependences in $Cd_{1-x}Zn_xTe$ crystals at T = 4.2, 77 and 295 K. As one can see, the shapes of the mentioned $hv_m(D^0X, A^0X)$ calibration dependences at T = 4.2, 77and 300 K are close to each other, *i.e.* depend weakly on temperature. As it was shown, the shapes of the discussed $hv_m(D^0X, A^0X)$ vs. x calibration dependences are mainly determined by the corresponding E_g vs. x variations. It follows from this that the shapes of the bandgap E_g vs. x variations depend weakly on temperature. Obviously, the difference between $hv_m(D^0X)$ vs. x dependences at different temperatures is mainly determined by the corresponding differences in the E_g vs. x calibration dependences, *i.e.* at any x 4.2 K $hv_m(D^0X) - 77 \text{ K } hv_m(D^0X) = 4.2 \text{ K } E_g - 77 \text{ K } E_g, 4.2 \text{ K}$ $hv_m(D^0X) - 300 \text{ K } hv_m(D^0X) = 4.2 \text{ K } E_g - 300 \text{ K } E_g$ and 77 K $hv_m(D^0X) - 300$ K $hv_m(D^0X) = 77$ K $E_g - 300$ K E_g . Evidently, the difference between the 4.2 K $hv_m(D^0X)$ and 4.2 K $hv_m(A^0X)$ calibration dependence is close to $\varepsilon_{bA} - \varepsilon_{bD}$ (obviously, $h\nu_m(A^0X) = E_g - \varepsilon_{bA}$ and $h\nu_m(D^0X) =$ $E_g - \varepsilon_{bD}$ at T = 4.2 K).



Fig. 4. The $hv_m(D^0X)$ (1-3) and $hv_m(A^0X)$ (1') vs. x calibration dependences in Cd_{1-x}Zn_xTe crystals at T = 4.2 (1, 1'), 77 (2) and 295 K (3).

4. Conclusion

Measurements of the 4.2, 77 and 295–300 K peak position of the edge emission band (A^0X, D^0X, D^0h, X) and *e*–*h* induced) are convenient to find the Cd_{1–x}Zn_xTe composition *x*. But found from the analysis of the 4.2 K

 $hv_m(A^0X)$ vs. x dependences x values are characterized by definite inaccuracies. It is related with some unknown factors influencing the 4.2 K peak position of the A^0X induced emission band (the 4.2 K energy position of A^0X complex). Naturally, pointed results in appearance of a number of 4.2 K $hv_m(A^0X)$ vs. x calibration curves for a given set of x values. So, to increase the accuracy of xdetermination via the analysis of 4.2 K $hv_m(A^0X)$ vs. x dependences one needs to find the factors influencing the 4.2 K $hv_m(A^0X)$ values, *i.e.*, the energy of the 4.2 K $A^{0}X$ bound exciton. A notable unexpected difference of the 295 K $hv_m(D^0X) = \varphi(x)$, 300 K $hv_m(D^0h) = \varphi(x)$ and 300 K $hv_m(eh) = \varphi(x)$ calibration curves is observed. Maybe, some weakly controlled unknown factors influence the 300 K $hv_m(D^0h)$ and 300 K $hv_m(eh)$ calibration dependences. Nevertheless, to explain correctly the discussed difference of $hv_m(X)$ calibration curves, one need to know the theoretically calculated in a general case the 295 K $hv_m(D^0X)$, 300 K $hv_m(D^0h)$ and 300 K $hv_m(eh)$ values at different x in Cd_{1-x}Zn_xTe crystals.

Appendix

Temperature variations of peak emission intensities, emission peak positions and half-widths of the A^0X and D^0X induced luminescence bands in $Cd_{1-x}Zn_xTe$ crystals of difference composition

Here, we pay attention to temperature variations of peak intensities *I*, emission peak positions hv_m and half-widths *w* of the luminescence bands induced by annihilation of A^0X and D^0X bound excitons. The data obtained will permit us to find in Cd_{1-x}Zn_xTe crystals with x = 0, 0.04, 0.01, 0.2 and 0.28 the origin of bound excitons that dominate in formation of the 4.2, 77 and 295 K edge emission spectra.

Fig. 5 and 6 show temperature variations of the excitonic part of $Cd_{1-x}Zn_xTe$ edge emission (x = 0.1 and 0.2). For the mentioned crystals with x = 0, 0.04, 0.01, 0.2 and 0.28, as one can see, both A^0X and D^0X induced emission bands are clearly seen at T = 4.2 K (the broad 4.2 K A^0X induced emission band dominates over the rather narrow 4.2 K D^0X induced emission [15-17]). The D^0X induced emission band dominates in the excitonic spectra at $T \ge 30$ K.

Fig. 7 shows temperature variation of peak intensities in the A^0X and D^0X induced emission bands. These emission intensities are nearly constant at low temperatures and are thermally quenched at high temperatures. The thermally induced decrease in the concentrations of neutral shallow acceptors A^0 and donors D^0 and free excitons X, the thermal dissociation of A^0X and D^0X bound excitons are responsible for the above factors. A definite contribution to the discussed emission quenching of A^0X and D^0X emission bands could be given by the non-radiative recombination process of free charge carriers. The discussed quenching is much stronger for the induced emission band, so at

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moderate and high temperatures the D^0X induced emission band dominates in the $Cd_{1-x}Zn_xTe$ edge spectrum (the A^0X induced emission band is not observed at high temperatures), see Figs 5 and 6.



Fig. 5. Temperature variations of the excitonic emission spectra in $Cd_{1-x}Zn_xTe$ crystals with x = 0.1 and 0.2. Correlation between the emission intensities at different temperatures is arbitrary.



Fig. 6. Temperature dependence of the excitonic emission spectra in $Cd_{1-x}Zn_xTe$ crystals with x = 0, 0.04 and 0.28. The correlation between the emission intensities for various temperatures is arbitrary.



Fig. 7. Temperature variations of the peak emission intensities of the A^0X (*I*-5) and D^0X (*I'*-5') luminescence bands in $Cd_{1-x}Zn_xTe$ crystals with x = 0 (*I*, *I'*), 0.04 (*2*, *2'*), 0.1 (*3*, *3'*), 0.2 (*4*, *4'*) and 0.28 (*5*, *5'*). Correlation between $I(A^0X)$ and $I(D^0X)$ values for the same crystals is the real one. Correlation between $I(A^0X)$ and $I(D^0X)$ values in different crystals is arbitrary.

Fig. 8 shows the temperature variation of the peak position of the A^0X and D^0X emission bands hv_m in $Cd_{1-x}Zn_xTe$ crystals with x = 0, 0.04, 0.01, 0.2 and 0.28. As one can see, the peak positions of the D^0X induced emission bands shift to lower hv_m values as the temperature is raised. This temperature shift could be satisfactory described by the following empirical relation (see [17]):

$$hv_m(T) = hv_m(0) - \frac{AT^2}{T+B},$$
 (A1)

where $hv_m(0)$ is the hv_m value at T = 0 K ($hv_m(0) = 1.5937$, 1.6141, 1.65, 1.667 and 1.741 eV at x = 0, 0.04, 0.01, 0.2 and 0.28, accordingly), $A = 6.48 \cdot 10^{-4}$ eV/K and B = 264 K.

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Fig. 8. Temperature variations of the peak position hv_m of the A^0X (1-5) and D^0X (1'-5') induced emission bands in $Cd_{1-x}Zn_xTe$ crystals of different Zn composition: x = 0 (1, 1'), 0.04 (2, 2'), 0.1 (3, 3'), 0.2 (4, 4') and 0.28 (5, 5').

As known [17], the mentioned Eq. (A1) describes (is characteristic for) the emission induced by radiative annihilation of D^0X bound excitons, *i.e.*, it describes hv_m vs. *T* variation of the D^0X induced emission band. So, the observed by the coincident of experimental and theoretical 4.2 to 295 K hv_m vs. *T* dependences confirm that the edge (exciton induced) emission band in Cd₁₋ _xZn_xTe crystals with x = 0, 0.04, 0.01 and 0.2 is really induced by radiative annihilation of D^0X excitons, *i.e.*, the D^0X induced emission band dominates in the 77 to 295 K edge emission spectra of crystals with x = 0, 0.04, 0.01 and 0.2. The dominance of the D^0X induced emission band in the 4.2 to 300 K in Cd_{1-x}Zn_xTe crystals with *x* lying between 0.07 and 0.14 was noted in [17].

In Fig. 9, the dependences of the half-width w of the A^0X and D^0X induced emission on temperature (T =4.2...295 K) in Cd_{1-x}Zn_xTe crystals with different Zn content x are given. In Fig. 10, the dependences of the half-width of the A^0X and D^0X induced emission bands wfor various temperatures (4.2...295 K) are also given. The shown $w(A^0X, D^0X)$ vs. x and T dependences were obtained from given in Figs 5 and 6 line shapes of the discussed emission bands. As one can see, the $w(A^0X, D^0X)$ values increase, as the temperature and Zn content are raised. It is related with the thermal and alloyed broadening A^0X and D^0X induced emission bands (see, for example, [1, 8]). Thus, the presented w(x, T) curves can be helpful in identification of the A^0X and D^0X induced emission bands in Cd_{1-x}Zn_xTe crystals.



Fig. 9. Dependence of the half-width *w* of the $A^0X(1-5)$ and $D^0X(1'-5')$ induced emission bands on temperature in Cd₁₋ _xZn_xTe crystals with different Zn: x = 0 (1, 1'), 0.04 (2, 2'), 0.1 (3, 3'), 0.2 (4, 4') and 0.28 (5, 5').



Fig. 10. Dependence of the half-width *w* of the $A^0X(1)$ and $D^0X(1'-3')$ induced emission bands in $Cd_{1-x}Zn_xTe$ crystals on their Zn composition *x* at different temperatures *T*: 4.7 (1, 1'), 77 (2') and 295 K (3').

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